

2 September 2016

THE SCIENCE OF HAIR CARE - A GOOD HAIR DAY

The Use of Surface Analysis Techniques in Hair Product Development

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LUCIDEON

Why surfaces are important?

- The surface controls factors such as:
 - Cleanliness
 - Biocompatibility
 - Adhesion strength
 - Wear performance
 - Wetting
 - Corrosion resistance
 - Optical properties e.g. colour/finish/shine
 - Electrical properties
 - Printability/paintability
 - . . . and many others



Problem solving on surfaces

- Surface analysis techniques measure the chemical and physical composition of the outermost atomic layers of a material

Chemical Composition

Secondary Ion Mass Spectrometry (SIMS)

X-Ray Photoelectron Spectroscopy (XPS)

Physical Characteristics

Optical microscopy

Scanning Electron Microscopy (SEM)

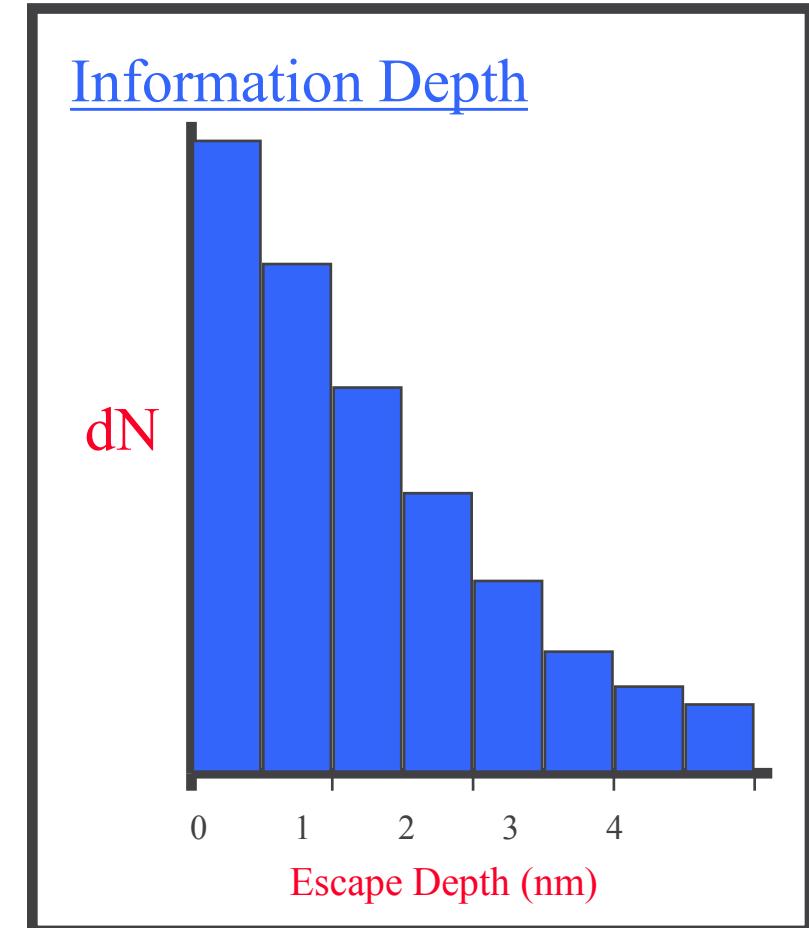
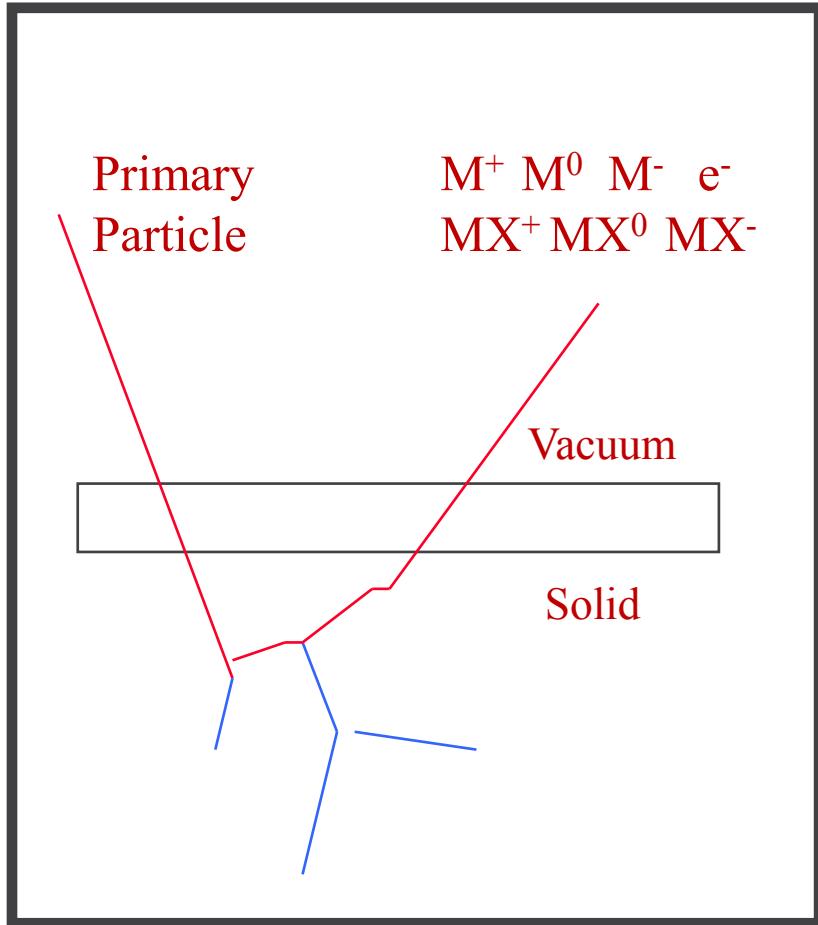
Surface Metrology - 3D profiling
White light interferometry

AFM - Atomic Force Microscopy
3DSEM

Stylus Profilometry (2D)

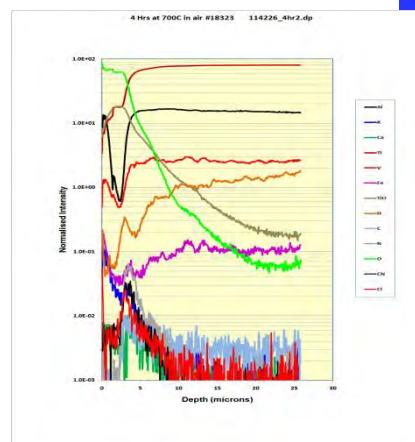
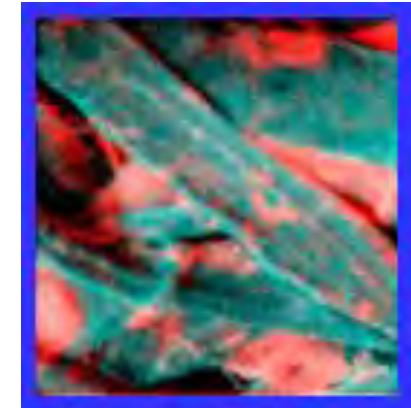
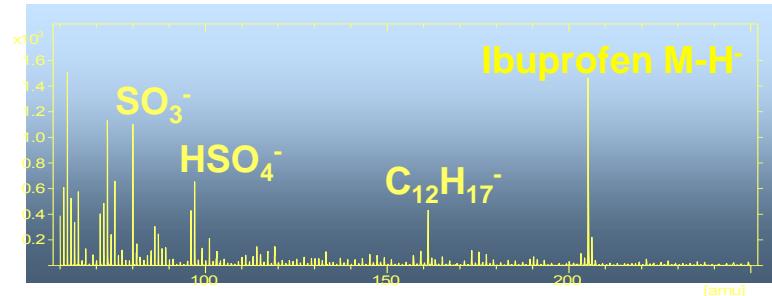


Secondary Ion Mass Spectrometry (SIMS)



SIMS modes and data output

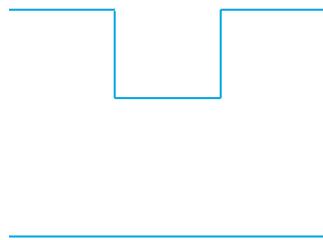
- Static SIMS
 - Minimal surface disruption
 - Fingerprint spectrum
- Dynamic SIMS
 - High etching rate
 - Depth profiling
- Imaging SIMS
 - Elemental and molecular mapping
 - Distribution of species



Dynamic SIMS vs static SIMS

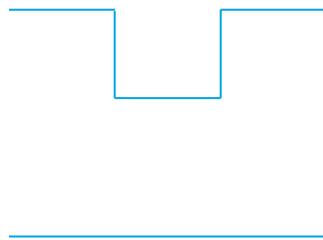
- DSIMS

Final state of surface



Elemental information
Depth profiling
Quantification
Bulk analysis ~10-30µm

- SSIMS



Elemental + molecular
information
Qualitative/semi-quantitative
Surface analysis ~1-2nm

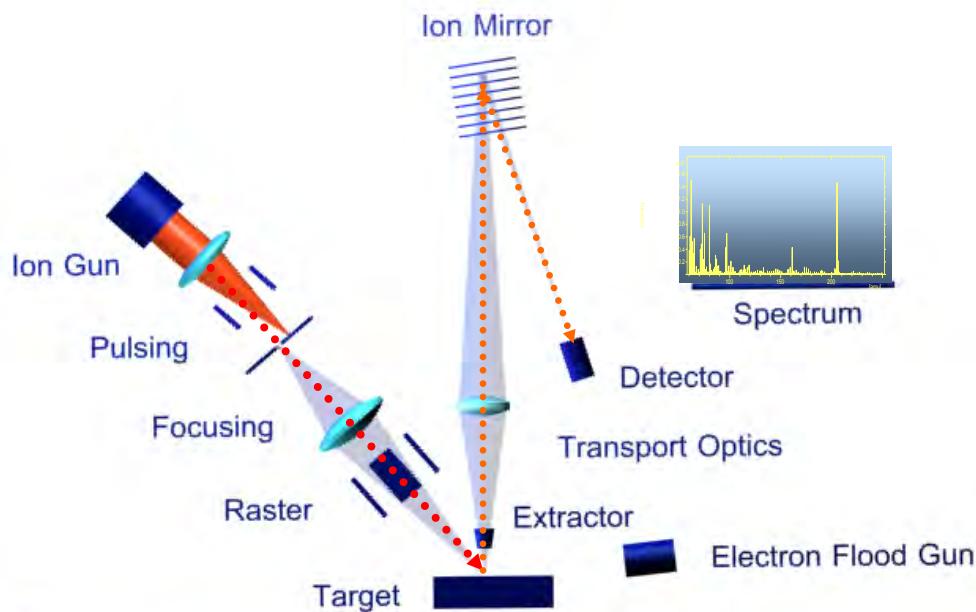
- In SSIMS, the chemical integrity of the surface is preserved during analysis
- Each primary impact affects a pristine area

Atomic surface density ~ 10^{15} at.cm⁻²

Static limit ~ 10^{12} ions.cm⁻²



Time-of-Flight SIMS



© ION-TOF GmbH

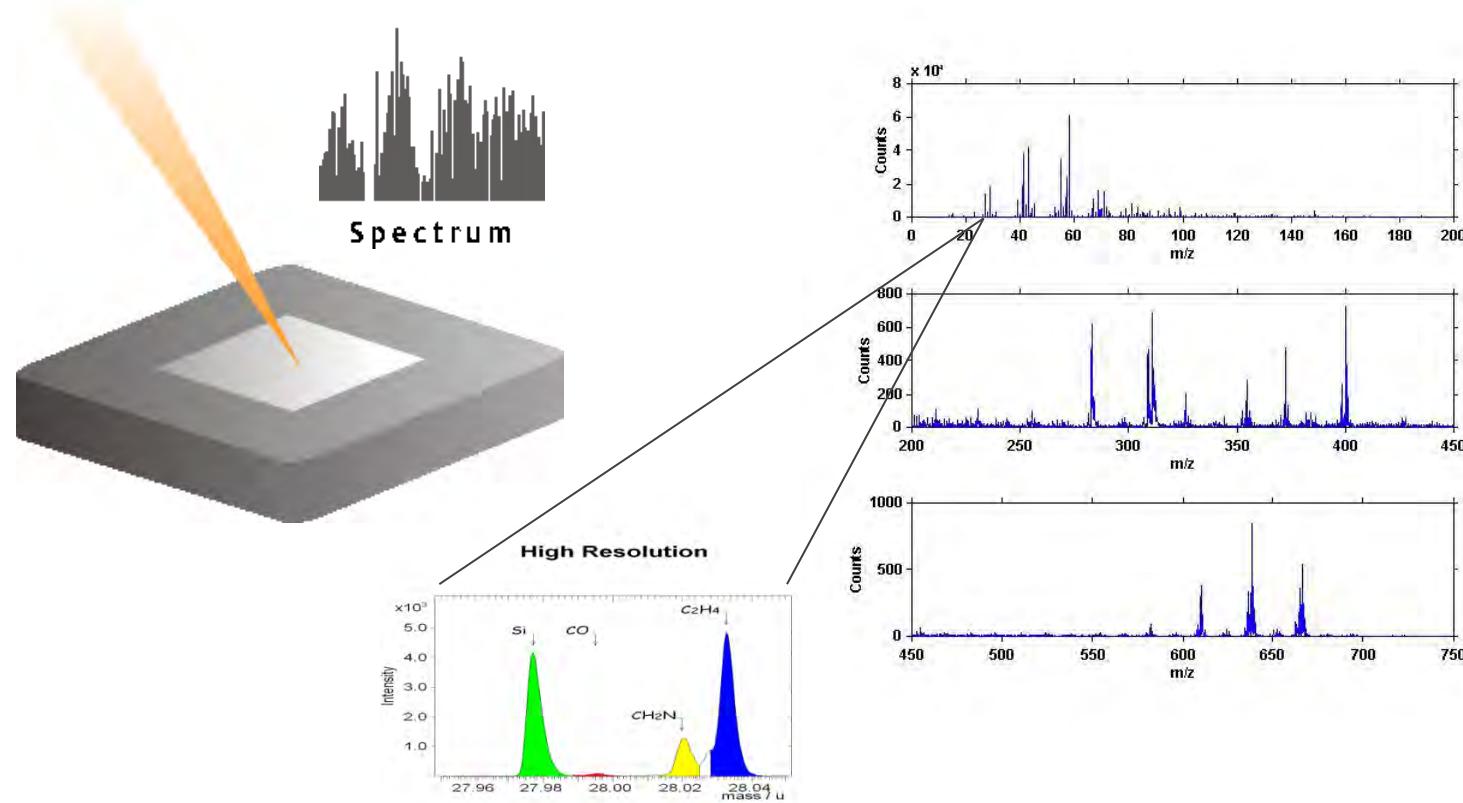
- High sensitivity
Parallel mass detection
- High mass resolution
Accurate Mass analysis
- Mass accuracy
1 - 10 ppm
- Mass range
Up to 10000 amu

Mass discrimination: the flight time of an ion varies as the square root of its mass



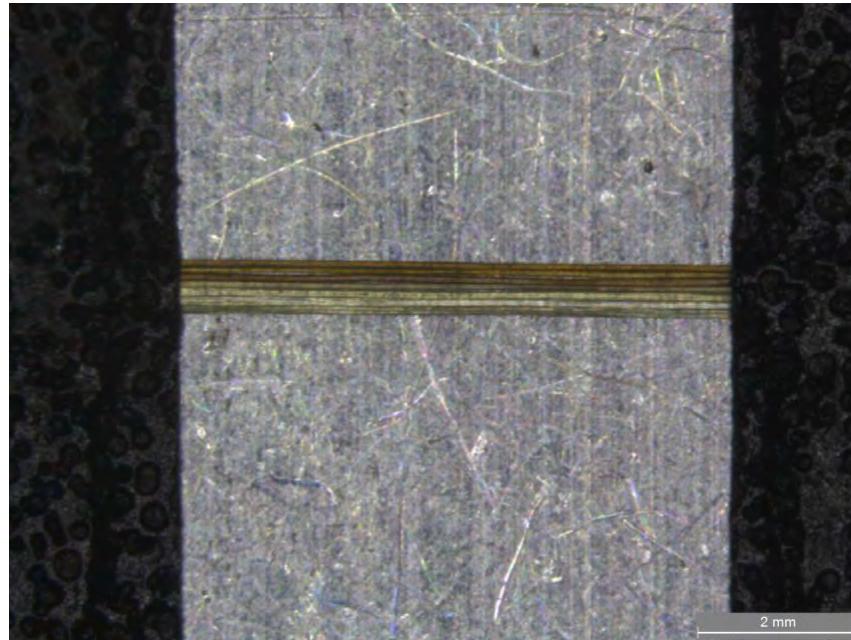
ToFSIMS - a mass spectrometry

Detailed chemical and molecular structure information



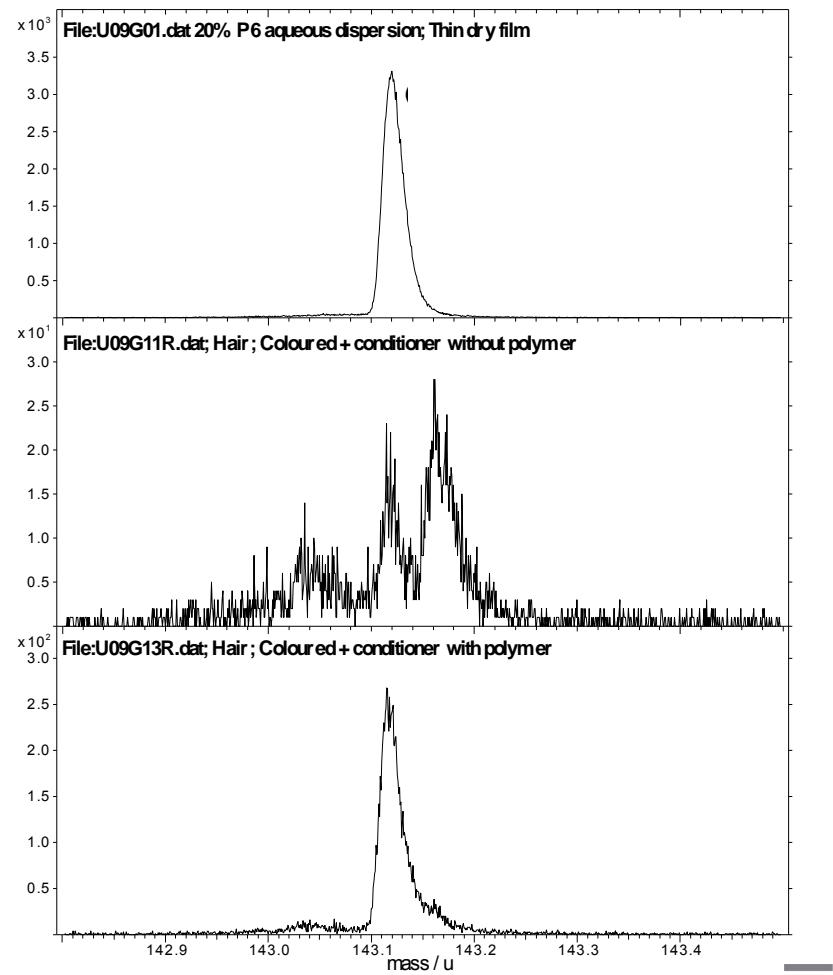
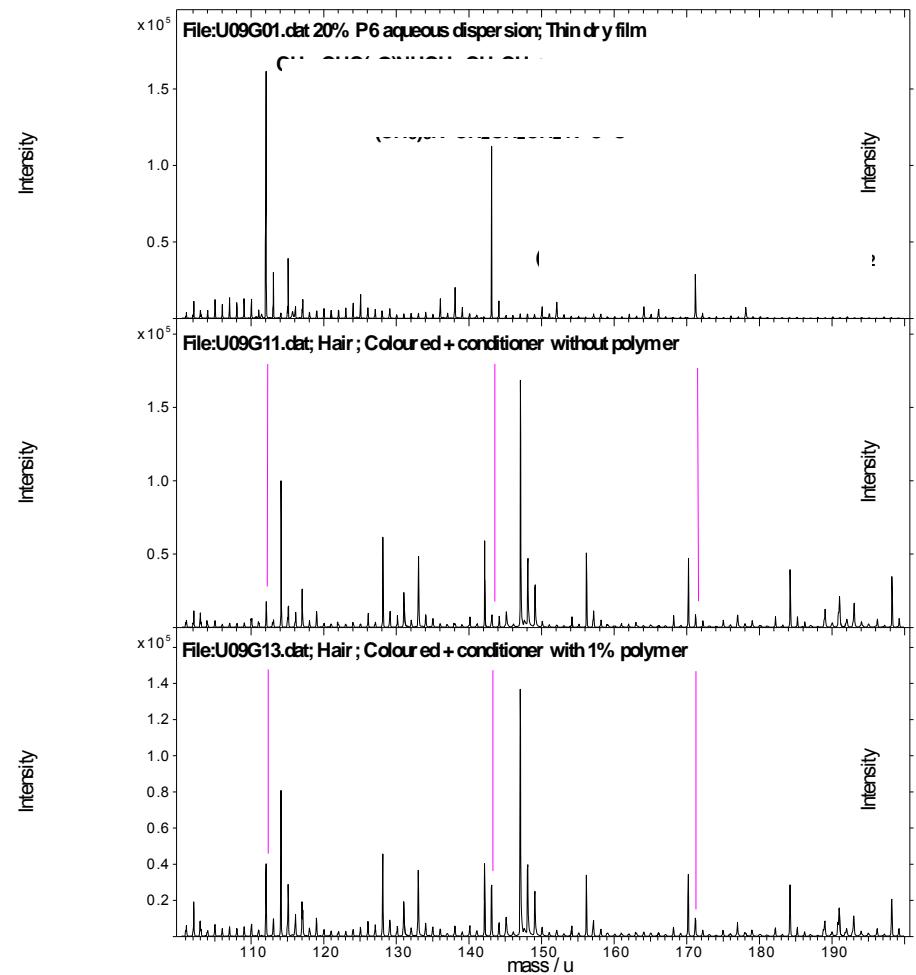
Hair analysis

- Fibres are generally difficult to analyse due to the curvature
- Mounting is a critical factor affecting the quality of images
 - Individual fibres mounted parallel against each other to form a “flat bed” and present a more uniform surface to minimise distortions due to field effects in the images



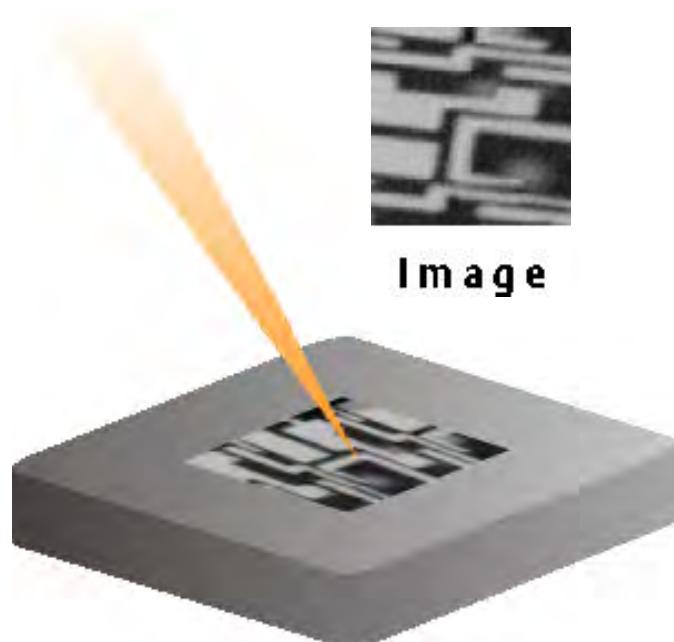
Identification of an active on conditioned hair

Active: polymeric quaternary amino chloride



ToFSIMS imaging

- Spatial distribution of species on the surface



Focused pulsed ion beam rastered over the surface

X, Y coordinates recorded with flight time of ions to produce mass resolved secondary ion images

Chemical mapping with sub-micron lateral resolution: < 200nm at best

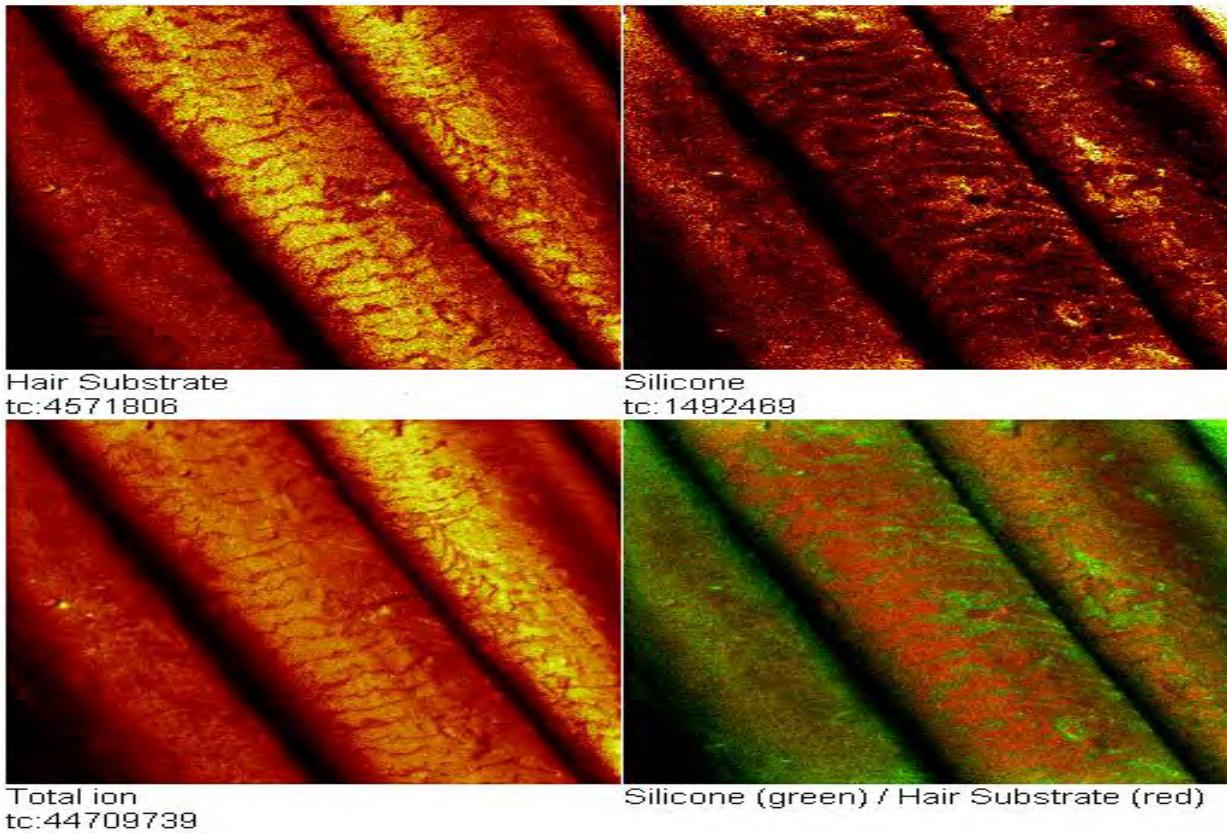
Typically used for areas < 150µm; larger areas (up to 500µm) ~3 - 5µm resolution used

- Retrospective analysis
- Spectrum-per-point (raw data) analysis
- Region-of-Interest reconstruction



Silicone-containing shampoo on bleached hair

Field of view: $150.4 \times 150.4 \mu\text{m}^2$



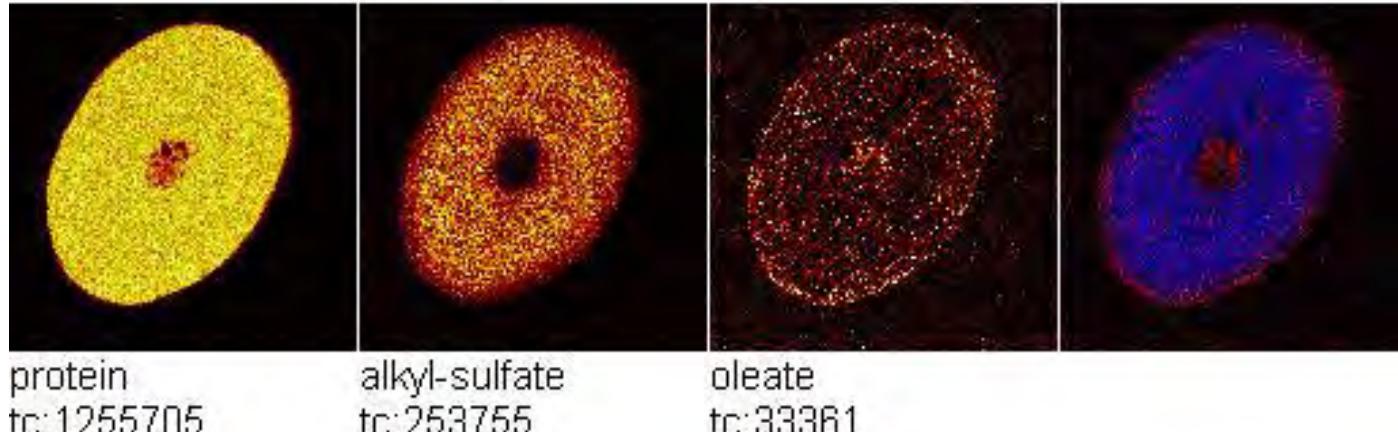
Silicone deposition is clearly identified and the signal intensity indicates how much silicone is present



Hair section

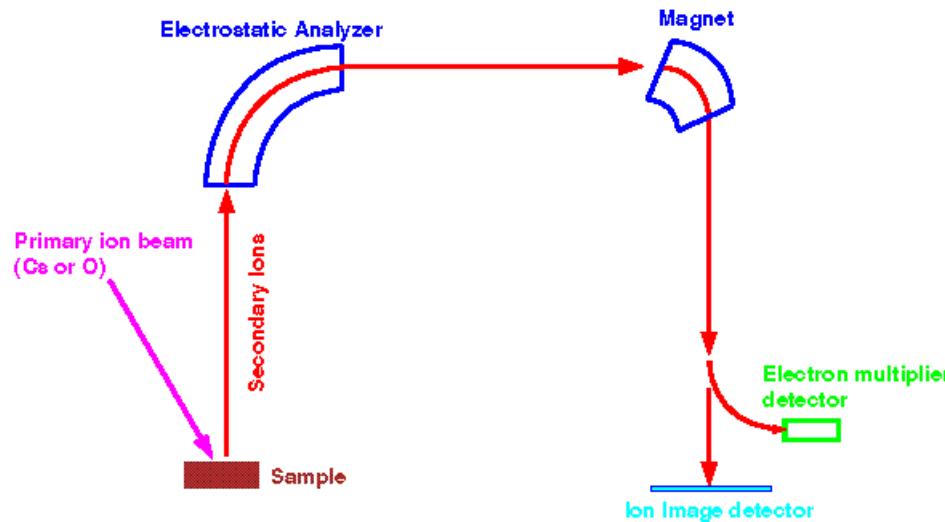
- Microtoming of hair embedded in resin
- Determination of penetration of species into the hair shaft

Field of view: $121.1 \times 121.1 \mu\text{m}^2$



DSIMS

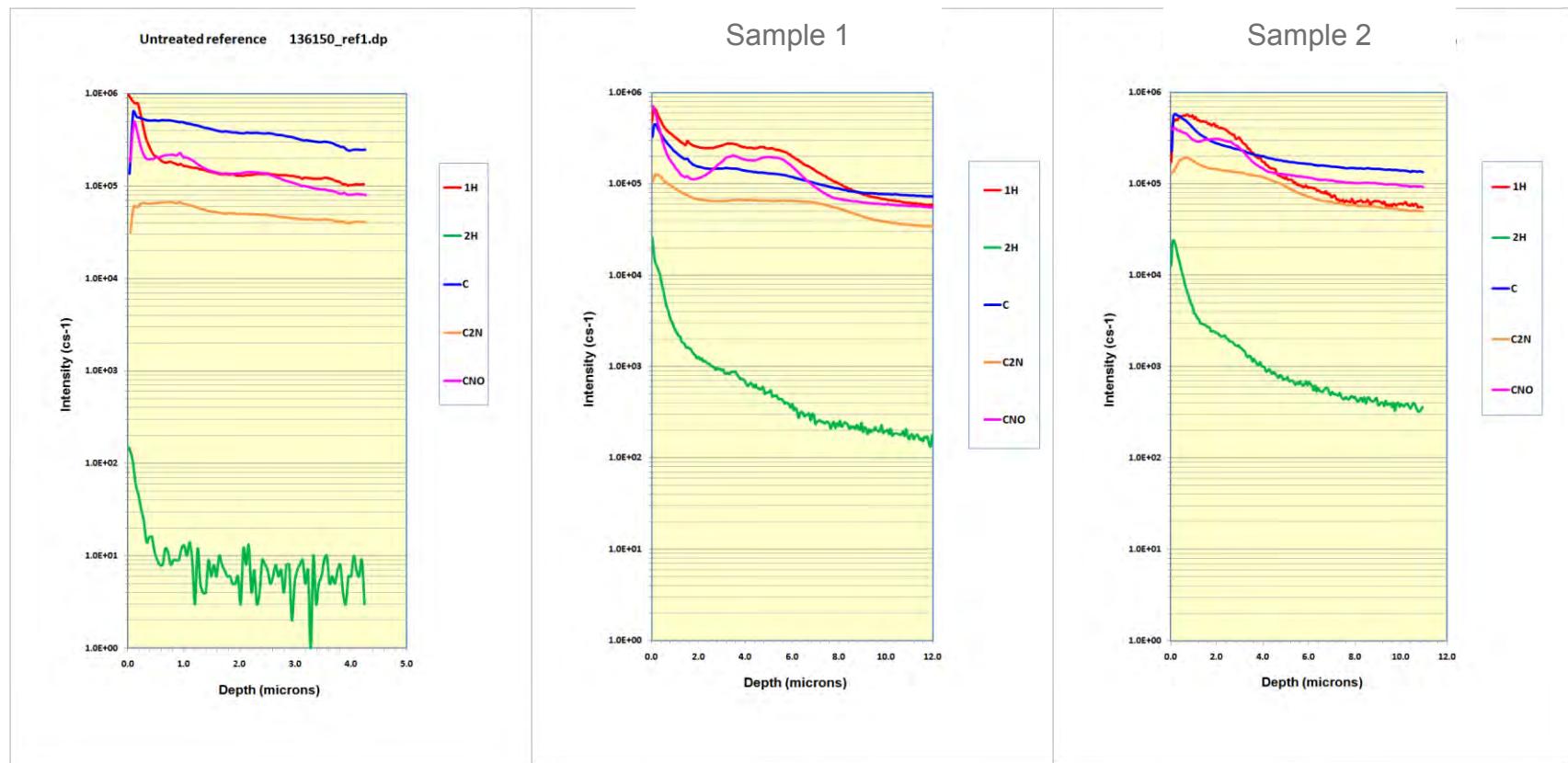
- Forces of electric field and magnetic field used for mass discrimination
- Scanned instrument
 - Higher primary ion doses hence more destructive and less suitable for organic materials
 - Elemental information mainly



Depth profiling

Deuteriation of small active molecules used in hair treatment

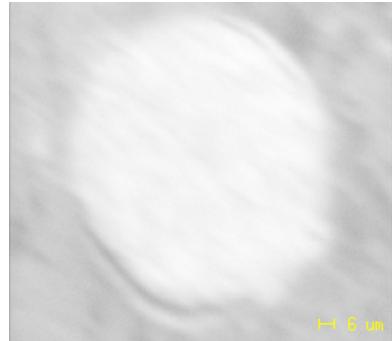
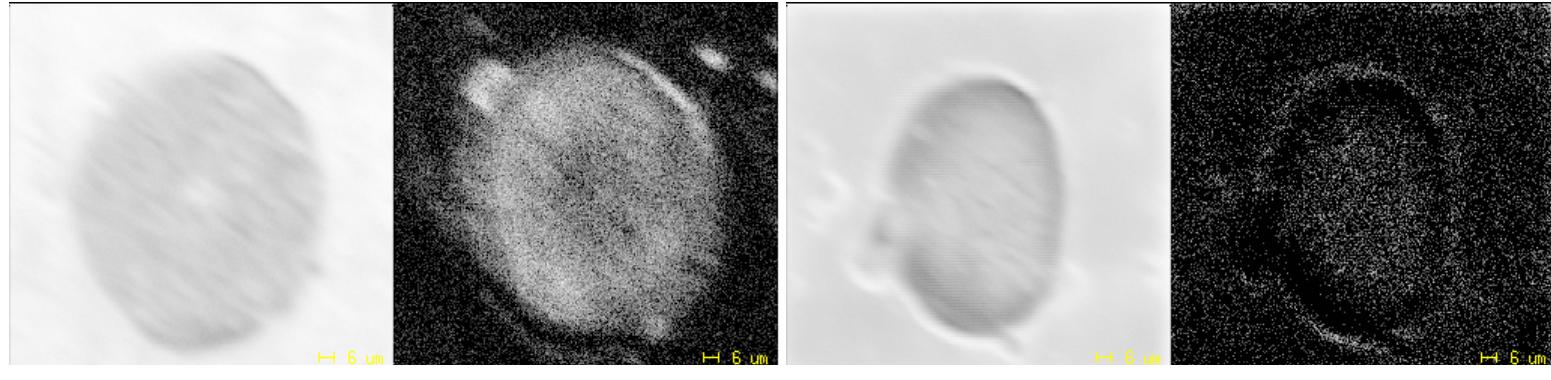
^2H signal used to monitor penetration of species



Untreated

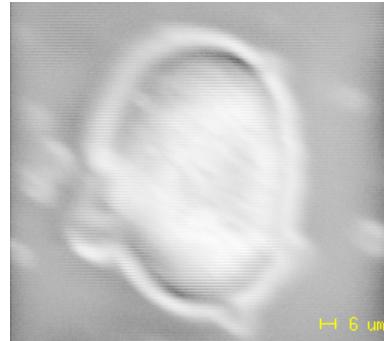
Penetration deeper than 12 microns

Hair section - imaging



136150_adiphph2g.im;12C 14N :1 Log[0..185]

Sample 1 pH2 left on

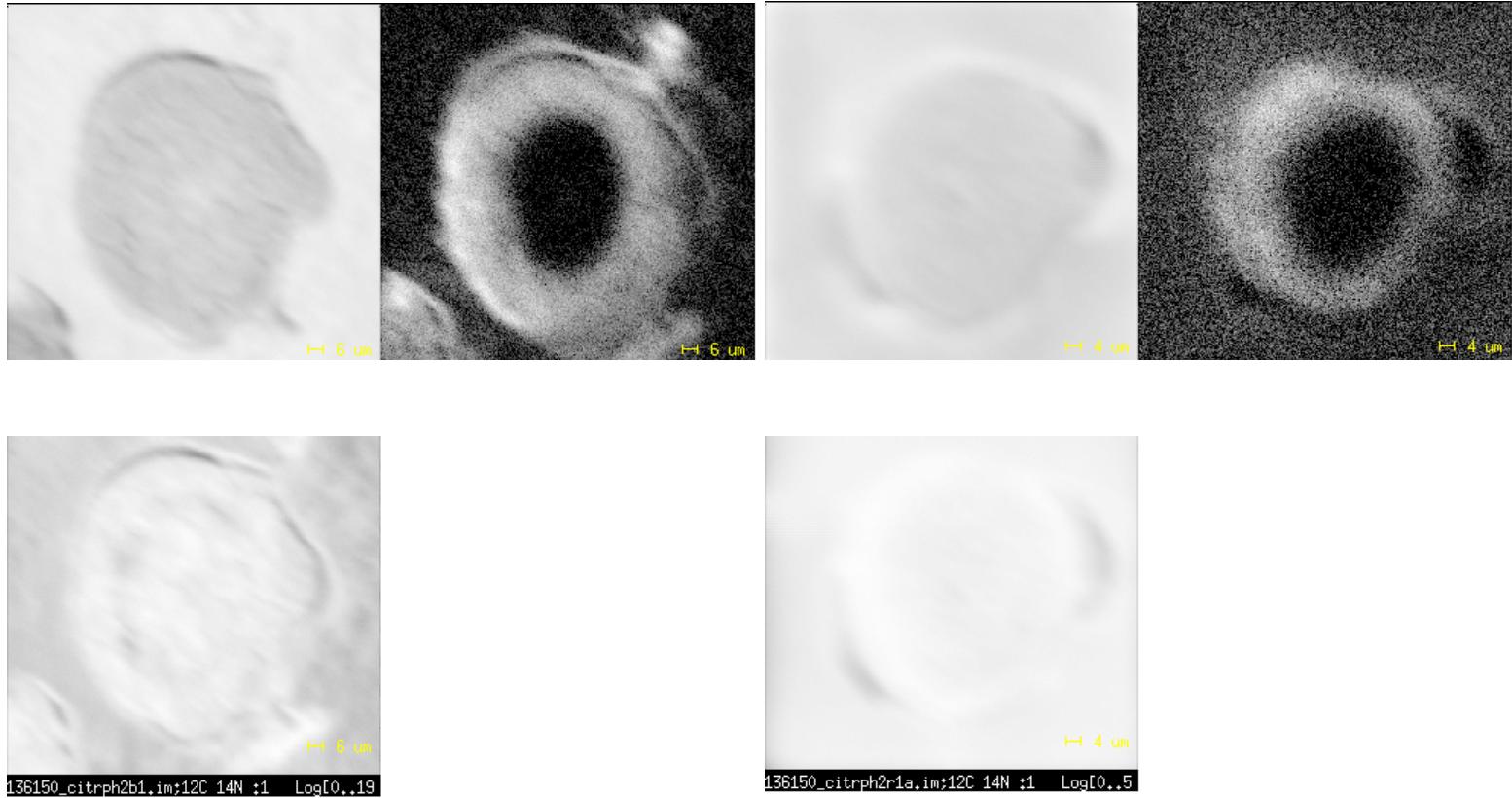


136150_adiph2r1b.im;12C 14N :1 Log[0..230]

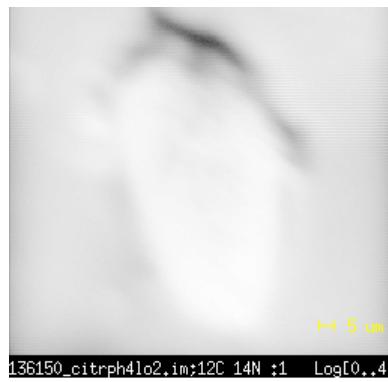
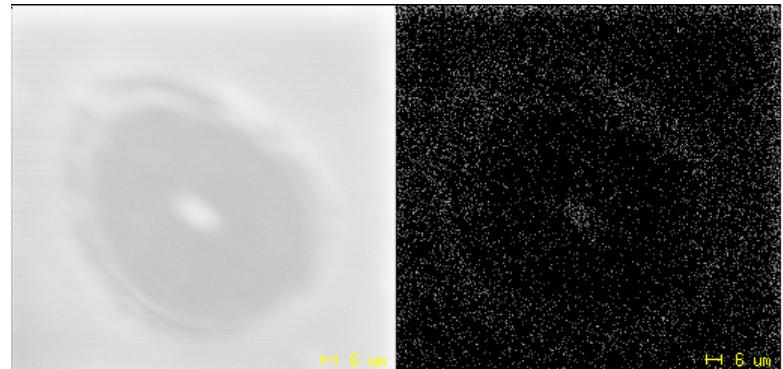
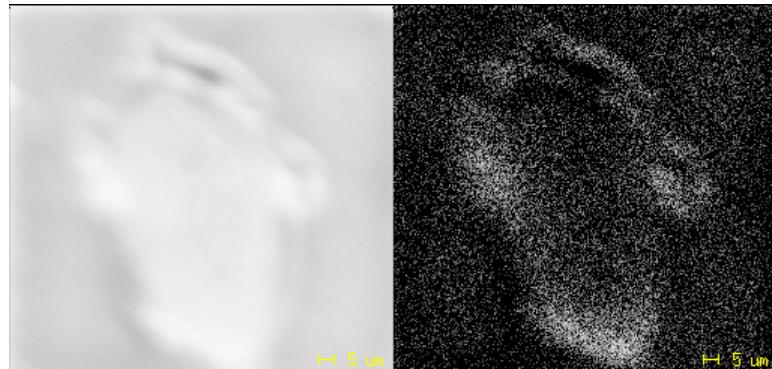
Rinsed



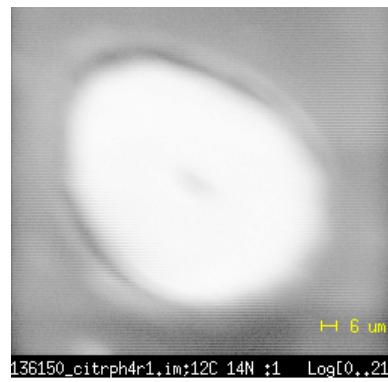
Hair section - imaging



Hair section - imaging



Sample 2 pH4 left on

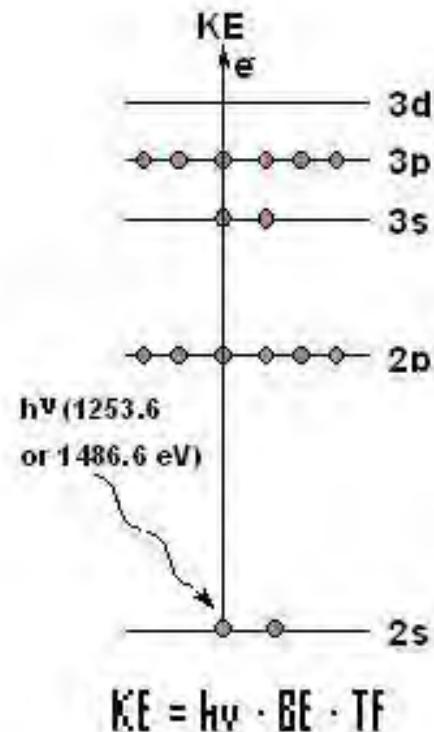


Rinsed



X-Ray Photoelectron Spectroscopy (XPS)

- Soft x-ray irradiation
- Ejects core level photoelectrons
Characteristic binding energy for elements
- Outer level electron relaxes to fill hole
- X-rays emitted
- Internally captured Auger electron emitted



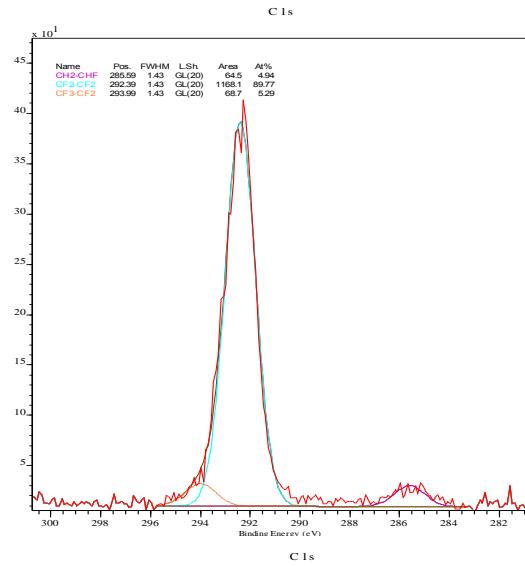
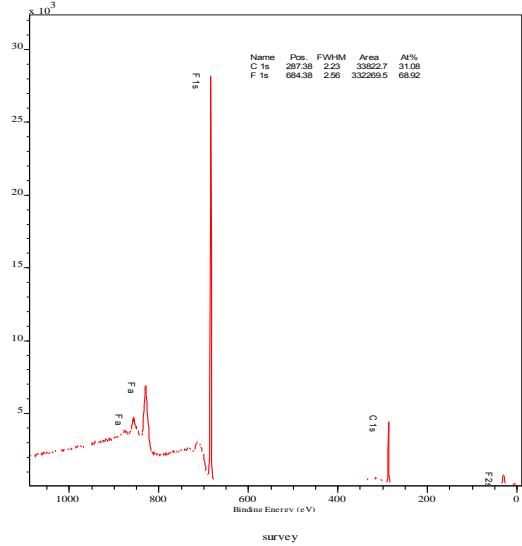
X-Ray Photoelectron Spectroscopy (XPS)

- Identification of all elements (except H and He)
- Conductors/insulators
- Elemental + chemical/oxidation states
- **Quantification**
- Surface specific (sampling depth <10nm)
- Surface imaging
- Depth profiling
- Complementary technique to ToFSIMS which is more molecular specific

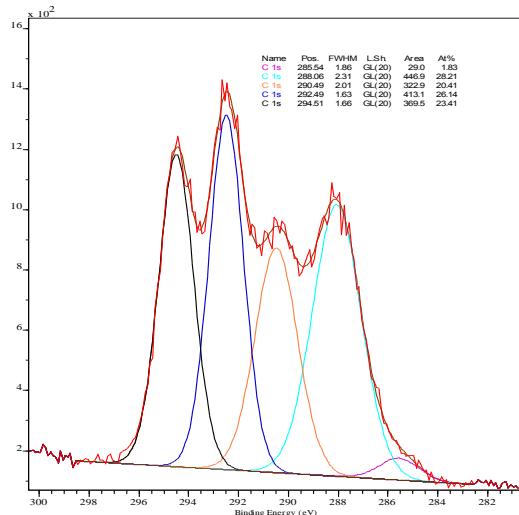
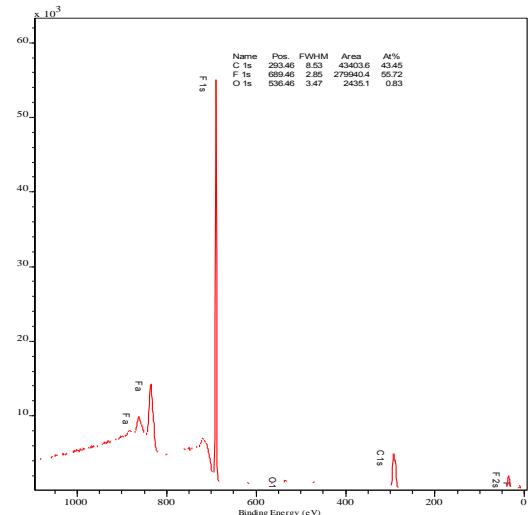


Spectroscopy

PTFE
Mon Apr 28 09:46:26 2003



PTFE



Complex
fluorocarbon

Survey spectra

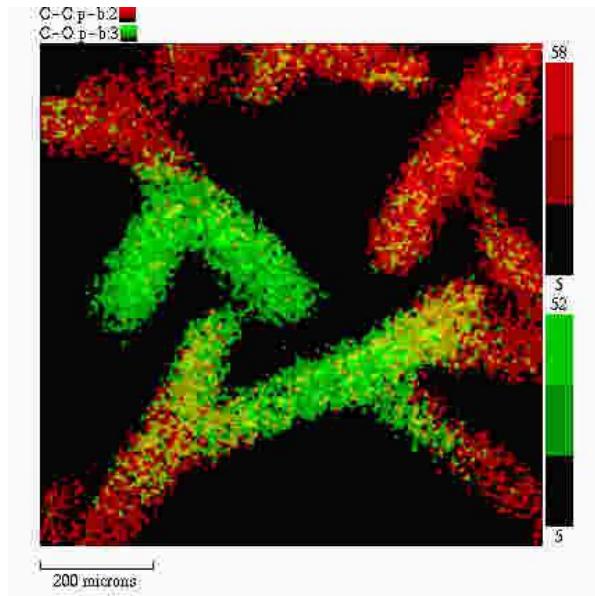
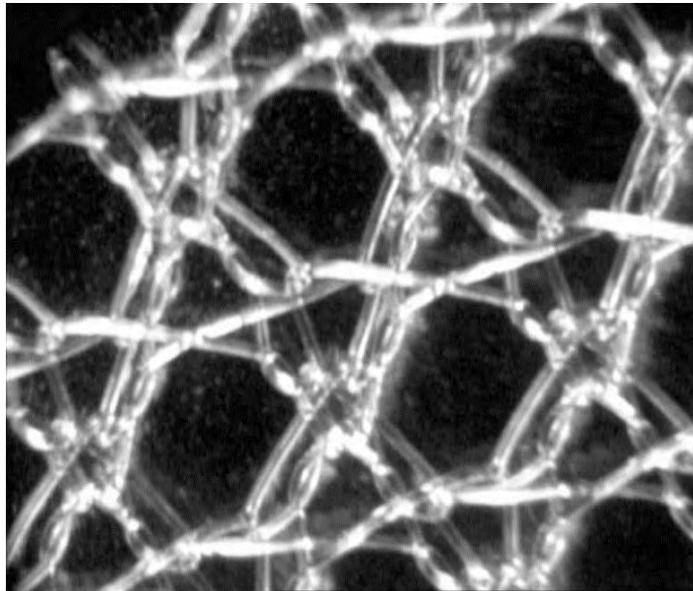
High resolution spectra

Quantification table output

Element	Tarnished Fluoropolymer coated samples					
	2-B1	2-B2	2-C1	2D-1	1-BC1	1-DE1
Carbon	32.9	32.4	35.0	34.8	33.6	35.5
σ	0.4	0.4	0.4	0.4	0.4	0.4
C-H/CH-CF	2.0	1.7	3.4	4.1	2.5	3.9
C-O/CH-CF ₂	1.5	1.2	1.8	1.6	1.6	1.7
C=O/CF	2.6	2.4	2.8	2.9	2.9	2.9
CF ₂	23.4	23.8	24.2	23.7	24.1	24.1
CF ₃	3.3	3.3	2.8	2.5	2.6	2.9
Fluorine	65.3	66.4	62.2	62.2	64.2	61.6
σ	0.4	0.4	0.4	0.4	0.4	0.4
Oxygen	1.9	1.2	2.9	3.1	2.2	2.9
σ	0.2	0.2	0.2	0.2	0.2	0.2
C-O-C	1.3	0.8	2.3	2.5	1.6	2.4
O-CF ₂	0.6	0.4	0.5	0.6	0.7	0.5
C-C/(CF ₂ + CF ₃)	0.075	0.063	0.125	0.154	0.092	0.142
Tarnish Index	2	4	5	5	6	5
Lucideon File	E5F0601	E5F0602	E5F0603	E5F0604	E5F0607	E5F0608

XPS imaging

Polypropylene mesh



Max. spatial resolution 3 μ m

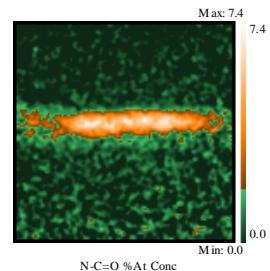
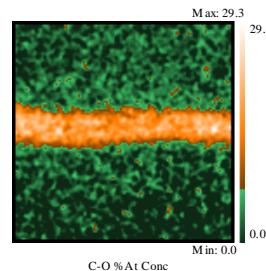
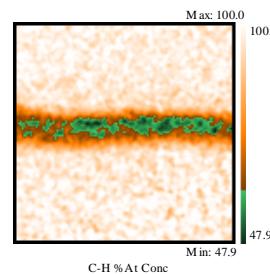
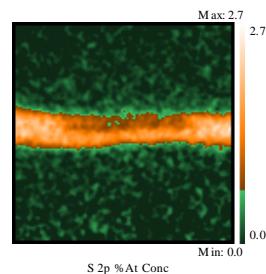
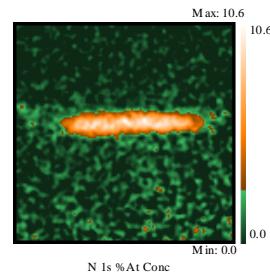
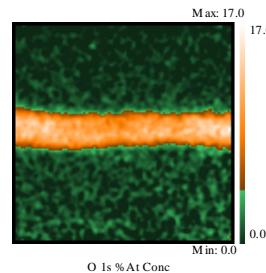
PP substrate = red
PEO coating = green



Hair section

~800μm x 800μm

- Hair embedded in epoxy resin between PE plates
- Magnification of the section due to angle cutting



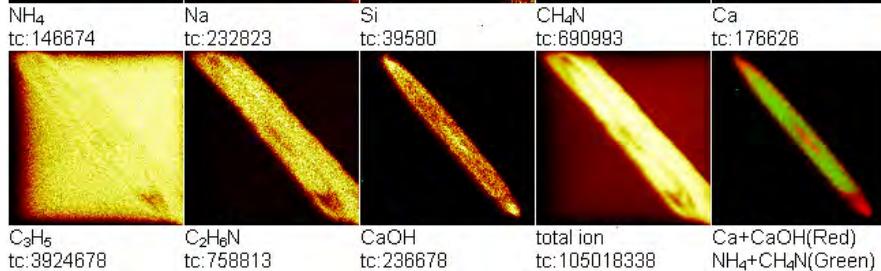
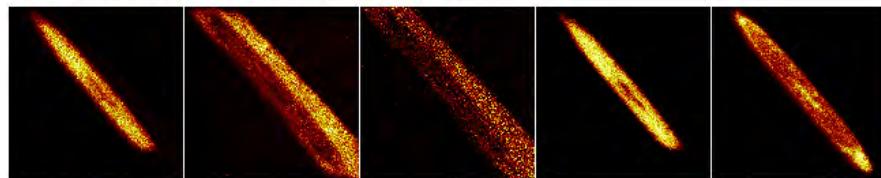
Spatial resolution 3μm, at best



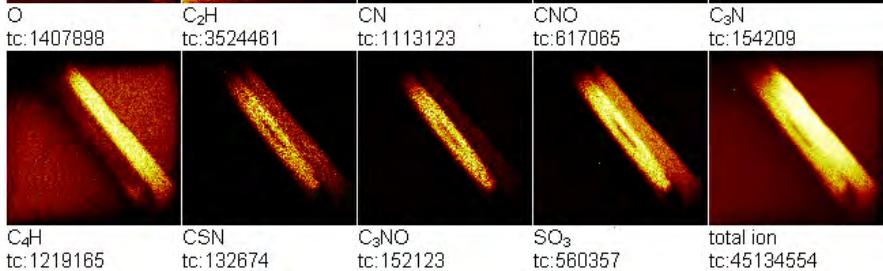
Hair section - XPS / ToFSIMS comparison

Low resolution

Field of view: 500.0 × 500.0 μm^2 ; Hair cross-section

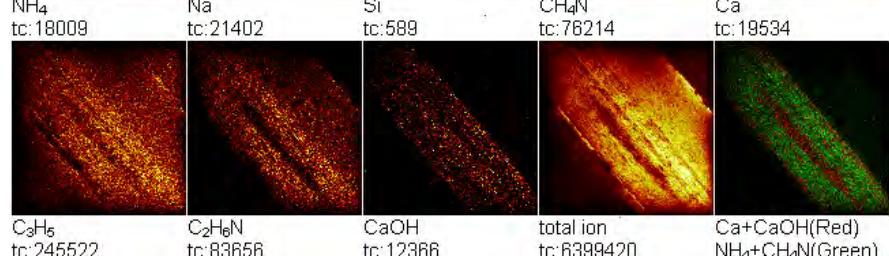
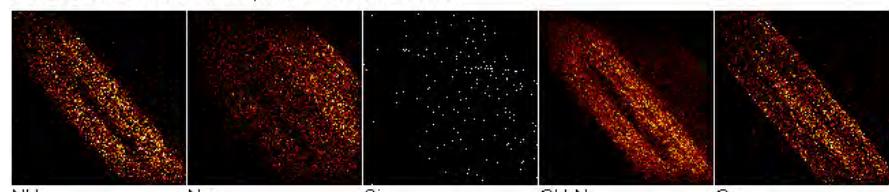


Field of view: 500.0 × 500.0 μm^2 ; Hair cross-section

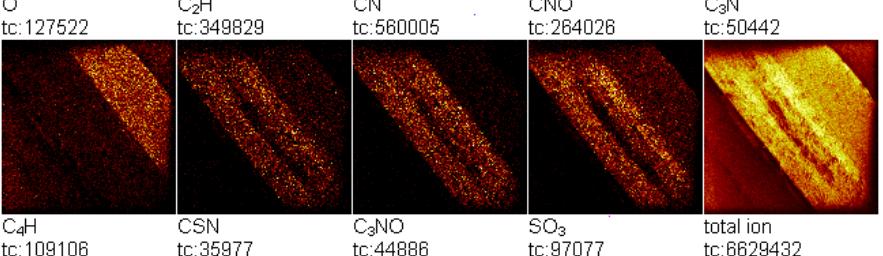
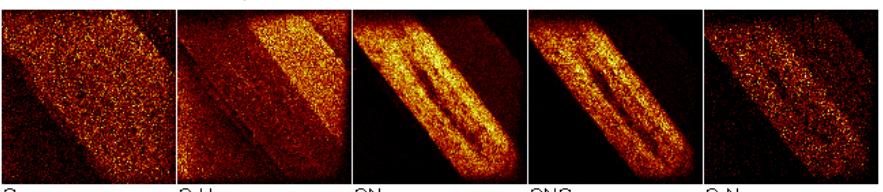


High resolution

Field of view: 150.0 × 150.0 μm^2 ; Hair cross-section



Field of view: 150.0 × 150.0 μm^2 ; Hair cross-section



Metrology

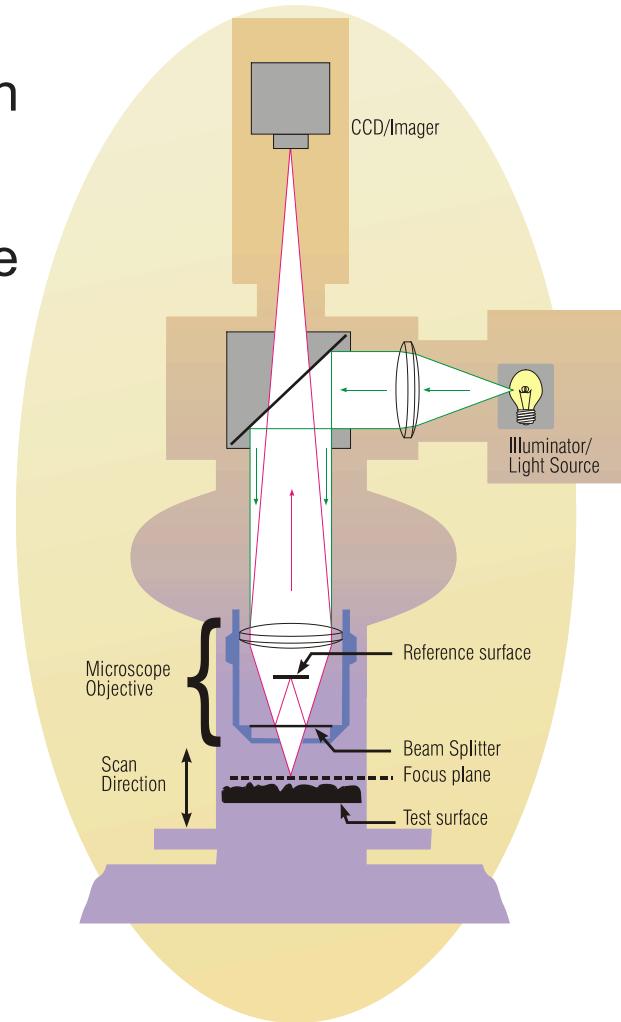
- Optical microscopy / SEM have limited topographical information - qualitative
- Need to quantify the topography
- Historically, contact method such as stylus profilometry used but can be problematic for soft materials with damage to the surface investigated
 - Also, only 2D line scans were measured
- Investment in non-contact profiling techniques



3D non-contact profiling by WLI

- Conventional bright-field microscope with an interferometer objective
- A *non-contact* 3D surface profiling technique utilising white light interferometry (WLI)
- High spatial and depth resolution in combination with a wide scanning area

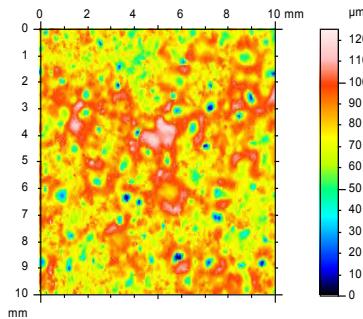
Height resolution ~1nm
Lateral resolution 0.5 μ m
Samples ~100 μ m to >10cm
Field of view 60 μ m to >10cm



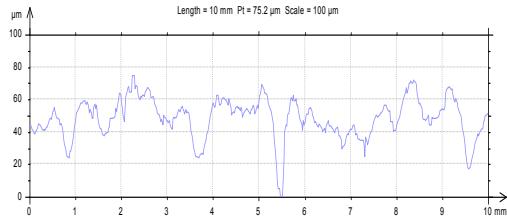
3D non-contact profiling by WLI

Quantitative measurement of surface topography and film thickness

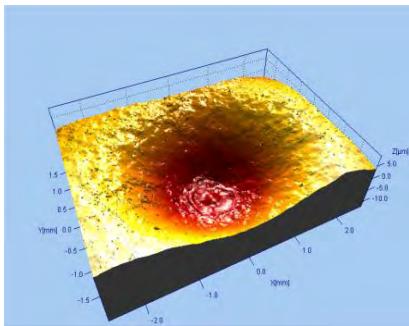
Pseudo-colour height map



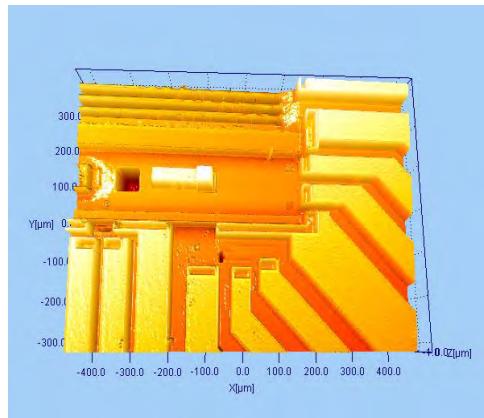
Line profiles



3D view



3D movie

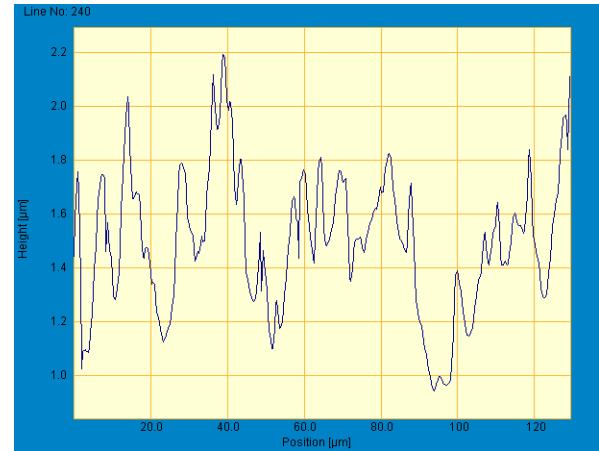
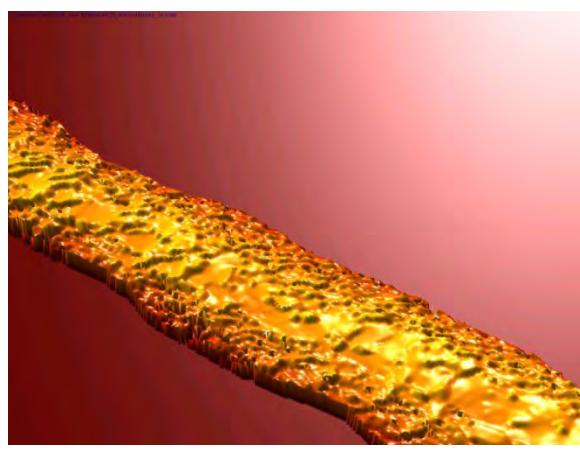


Amplitude Parameters	
Sa	10.6μm
Sq	14.0μm
Sp	43.4μm
Sv	79.5μm
St	123μm
Ssk	-0.752
Sku	4.82
Sz	118μm

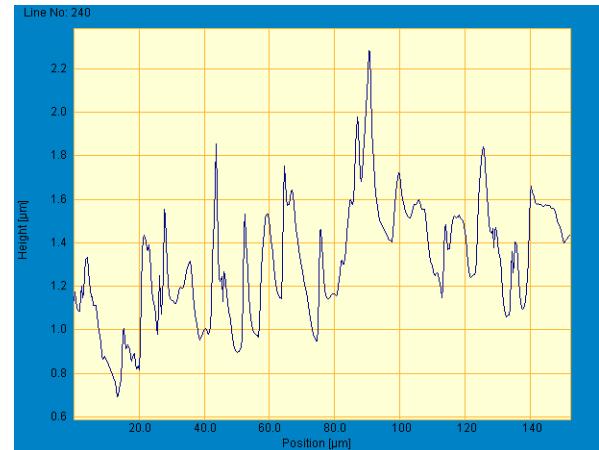
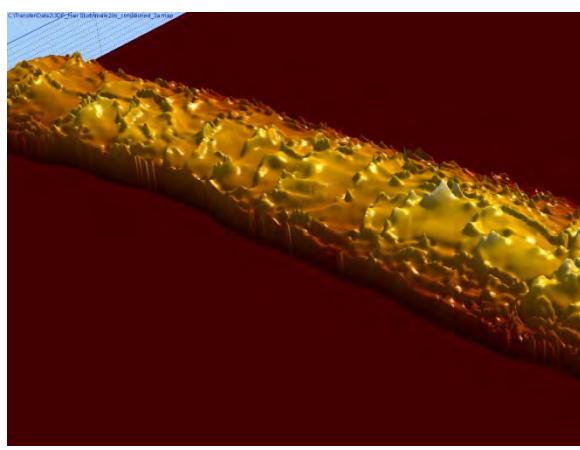
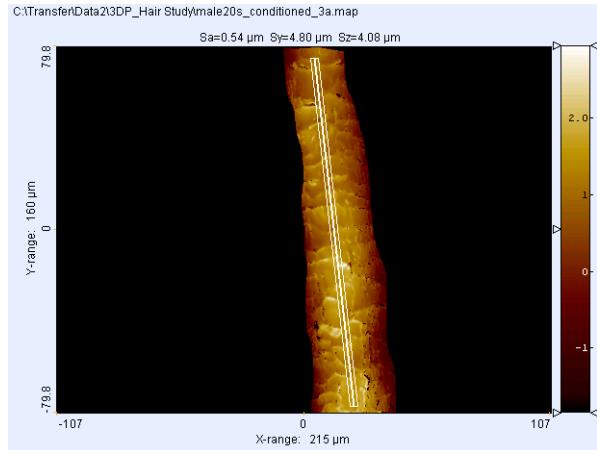
Roughness parameters, grain and pore analysis, transparent film thickness; sample replication



Effect of conditioning



Unwashed hair 48 hours



Conditioned hair

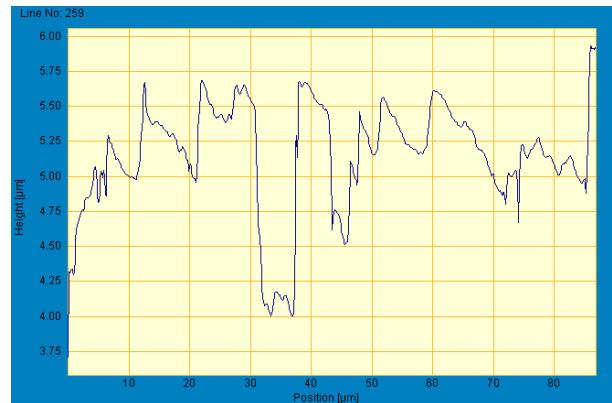
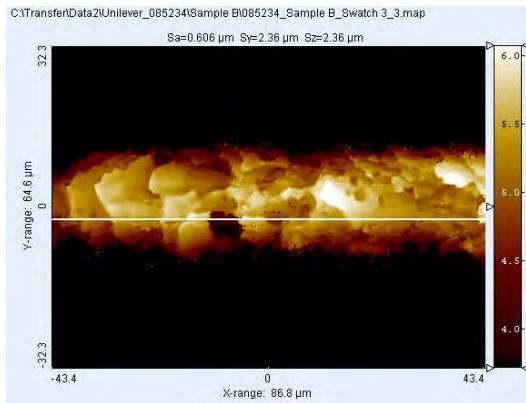
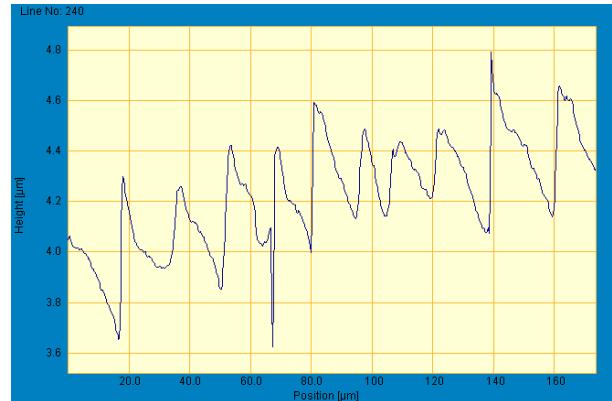
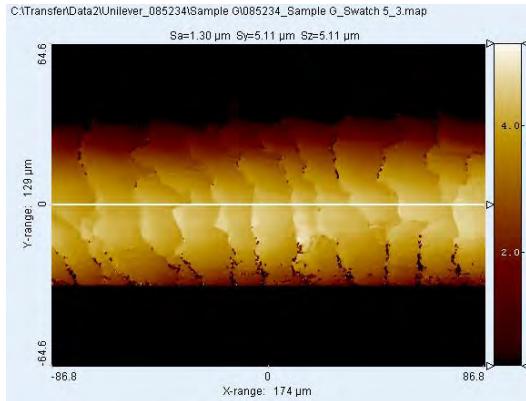
Effect of conditioning: roughness parameters

Description	Sample	Reading	Ra	Ry	Rz	Sample Mean Ra	Sample Mean Ry	Sample Mean Rz	Batch Mean Ra	Batch Mean Ry	Batch Mean Rz
Male 50s		a	0.27	1.64	1.30	0.25	1.45	1.20	0.25	1.45	1.20
		b	0.23	1.24	1.10						
		c	0.25	1.46	1.20						
Female 20s Conditioned	1	a	0.24	1.76	1.53	0.21	1.34	1.13	0.21	1.34	1.13
		b	0.19	0.98	0.86						
		c	0.20	1.27	1.01						
Female 20s Blonde Dyed	1	a	0.16	1.10	0.91	0.20	1.22	0.99	0.20	1.22	0.99
		b	0.29	1.65	1.30						
		c	0.15	0.90	0.75						
Male 20s Conditioned		a	0.189	1.38	1.06	0.18	1.25	1.02	0.19	1.28	1.01
		b	0.143	0.861	0.75						
		c	0.209	1.5	1.25						
	1	a	0.186	1.3	0.911	0.19	1.25	0.95			
		b	0.221	1.27	1.01						
		c	0.168	1.18	0.931						
	2	a	0.225	1.59	1.13	0.22	1.69	1.25			
		b	0.214	1.72	1.27						
		c	0.235	1.76	1.35						
	3	a	0.209	1.35	1.14	0.19	1.11	0.94			
		b	0.177	0.909	0.814						
		c	0.177	1.06	0.875						
	4	a	0.186	1.32	0.982	0.17	1.13	0.86			
		b	0.139	0.98	0.726						
		c	0.17	1.09	0.885						
Male 20s Unwashed (48 hours)		a	0.196	1.6	1.08	0.25	1.63	1.29	0.22	1.41	1.11
		b	0.345	1.8	1.53						
		c	0.223	1.5	1.25						
	1	a	0.219	1.57	1.22	0.22	1.58	1.15			
		b	0.235	1.93	1.31						
		c	0.207	1.25	0.916						
	2	a	0.26	1.51	1.26	0.22	1.31	1.07			
		b	0.189	1.18	0.909						
		c	0.205	1.25	1.04						
	3	a	0.188	1.36	0.883	0.19	1.28	0.96			
		b	0.215	1.45	1.1						
		c	0.168	1.02	0.885						
	4	a	0.225	1.13	1.04	0.23	1.23	1.07			
		b	0.266	1.62	1.31						
		c	0.185	0.94	0.871						

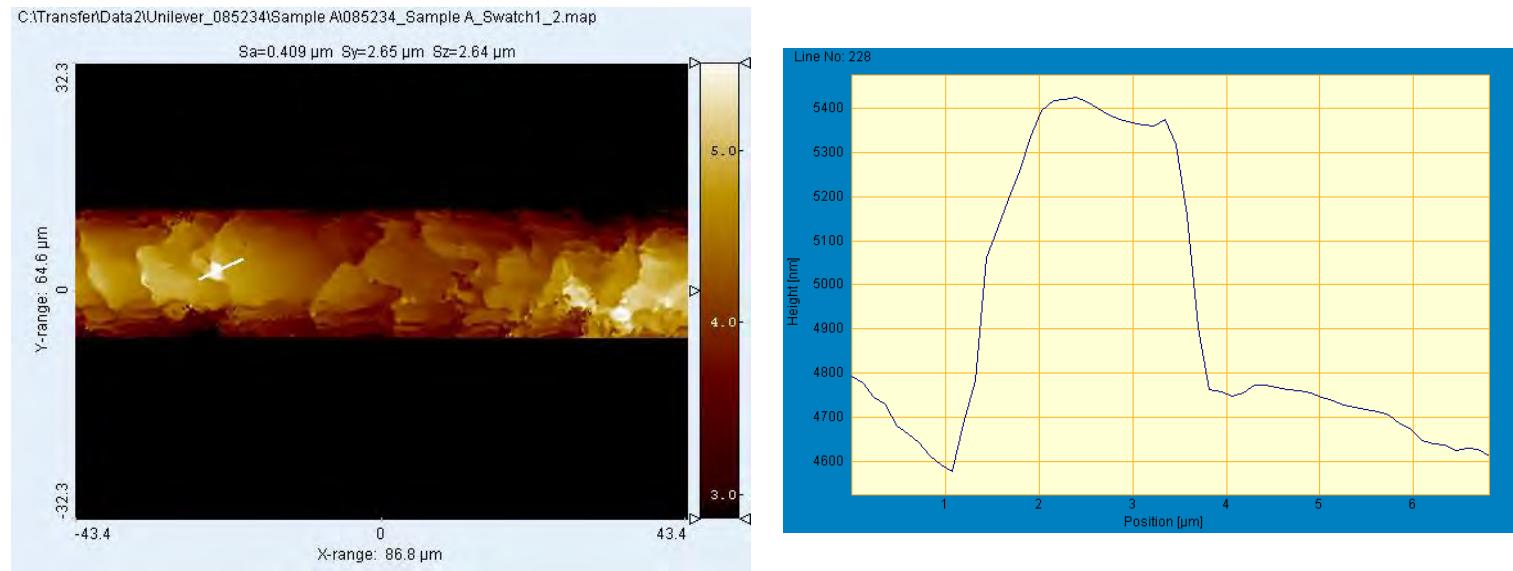
Decrease in
roughness values
by 9% – 13%
upon conditioning



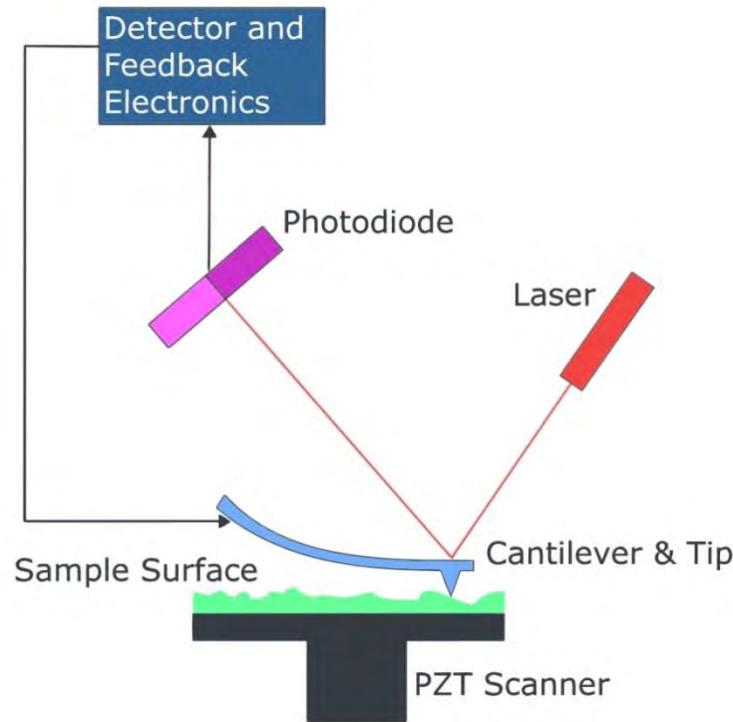
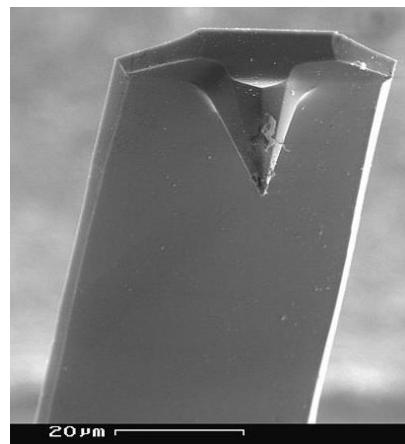
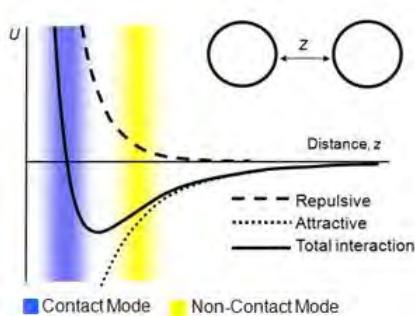
Scale height and particle measurement



Scale height and particle measurement



Atomic force microscopy



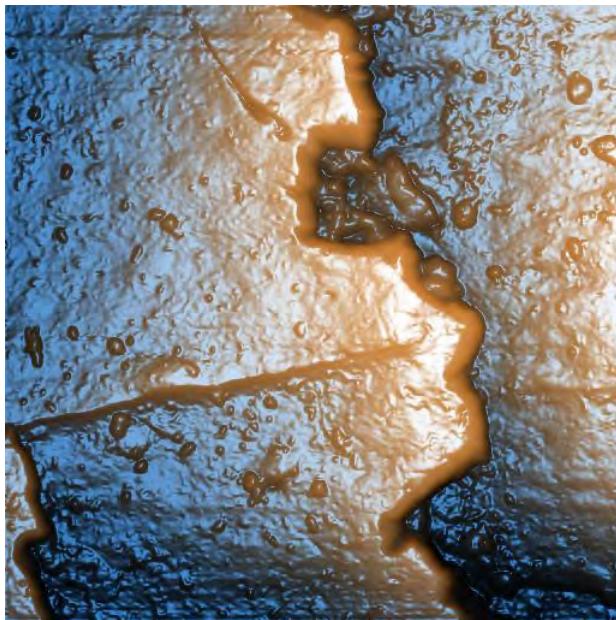
Common AFM modes

- Surface topography
 - (Contact and non-contact modes)
- Friction force
 - (Lateral force measurement)
- Hardness
 - (Force v distance curves)
- Electrical conductivity
- Magnetic force
- SEM resolution but in air or under liquids

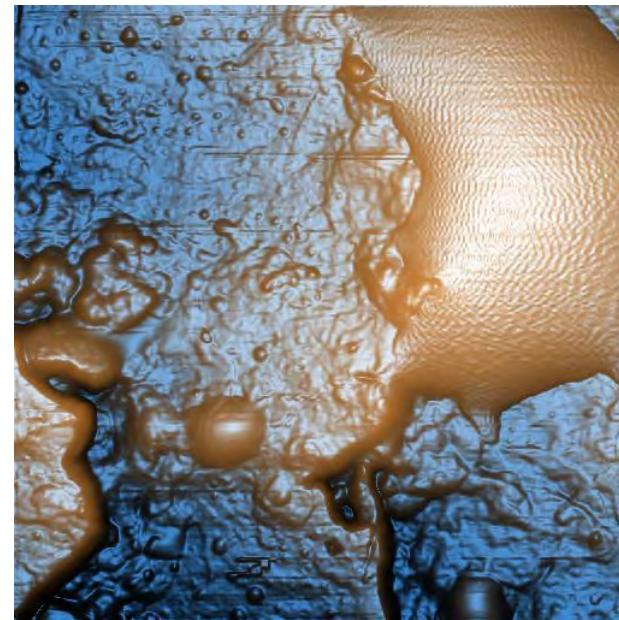


AFM of human hair (10 microns scan)

Before conditioner

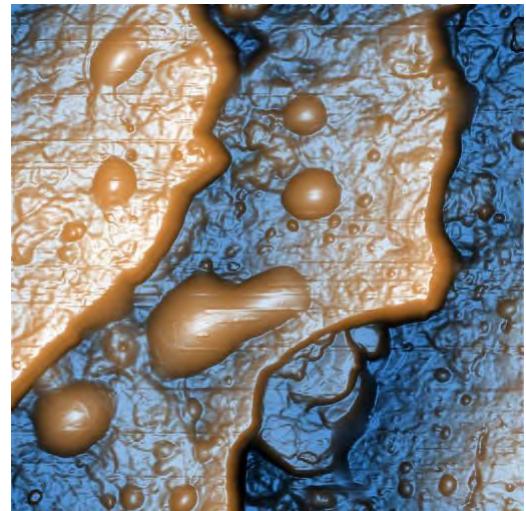


After conditioner

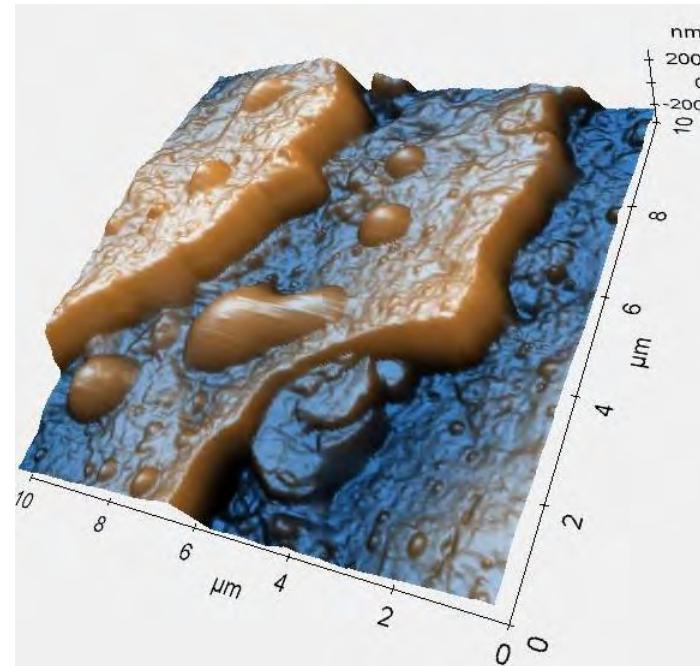


AFM of human hair (10 microns scan)

After conditioner



Isometric view



Line trace



Stitched images



Any questions?

LUCIDEON

Thank you

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